

Strain-driven multiple transitions in the magnetic anisotropy of Janus monolayer VSiGeN₄

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Strain is a very effective method to tune electronic states of two-dimension (2D) materials, which can induce unique phase transition. Recently, 2D MA₂Z₄ family materials are of interest because of their emerging topological, magnetic and superconducting properties. Here, we investigate the impact of strain effects ($a/a_0:0.96\sim 1.04$) on physical properties of Janus monolayer VSiGeN₄ as a derivative of VSi₂N₄ or VGe₂N₄, which possesses dynamic, mechanical and thermal stabilities. For out-of-plane magnetic anisotropy, with increasing strain, VSiGeN₄ undergoes ferrovalley semiconductor (FVS), half-valley-metal (HVM), valley-polarized quantum anomalous Hall insulator (VQAH), HVM and FVS. These imply twice topological phase transition, which are related with sign-reversible Berry curvature and band inversion between $d_{xy}+d_{x^2-y^2}$ and d_{z^2} orbitals for K or -K valley. The band inversion also leads to transformation of valley splitting strength between valence and conduction bands. However, for in-plane magnetic anisotropy, no special quantum anomalous Hall (QAH) states and valley polarization exist within considered strain range. The actual magnetic anisotropy energy (MAE) shows that the easy magnetization axis of VSiGeN₄ possesses a complex strain dependence, and several transitions in the magnetic anisotropy can be observed. The intrinsic phase diagram shows no special QAH and HVM states in monolayer VSiGeN₄. Fortunately, these can be easily achieved by external magnetic field, which can adjust easy magnetization axis of VSiGeN₄ from in-plane one to out-of-plane one. Because strain can effectively tune the correlation strength (U) of electron, the MAE as a function of U is calculated, which shows similar outline with MAE vs a/a_0 . Our findings shed light on strain effects on electronic states of VSiGeN₄, which may open new perspectives for multifunctional quantum devices in valleytronics and spintronics.

Keywords: Strain, Magnetic anisotropy energy, Phase transition

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I. INTRODUCTION

Magnetism of 2D systems is one of the most fascinating properties of material due to its interplay with the other important properties of materials such as superconductivity, ferrovalley (FV), ferroelectricity, piezoelectricity and QAH effects. However, based on Mermin-Wagner theorem, long-range magnetic order is prohibited in a 2D system¹. Fortunately, 2D intrinsic long-range ferromagnetic (FM) order semiconductors, Cr₂Ge₂Te₆ and CrI₃, have been achieved experimentally, from their van der Waals (vdW) layered bulk materials^{2,3}, which is because FM order can be stabilized by magnetic anisotropy. In addition to this, the direction of magnetic anisotropy has very important influence on topological and valley properties of some 2D materials, because it can affect the symmetry of 2D systems⁴⁻⁷. For example in monolayer RuBr₂, FV to HVM to QAH to HVM to FV transitions can be induced by increasing electron correlation U with fixed out-of-plane magnetic anisotropy, but no special QAH states and valley polarization can be observed for in-plane case⁷. Thus, it may be a very interesting thing to tune magnetic anisotropy of 2D systems by external field, such as biaxial strain, electric field, and correlation effects.

Strain engineering is an important strategy for tuning electronic, topological, thermoelectric, piezoelectric and magnetic properties of 2D materials, which has been widely used in the modulation of physical and chemical

properties⁸. The QAH state in the VN₂X₂Y₂ nanosheets (X=B-Ga, Y=O-Te) can be induced by strain, and the valley polarization can also be switched from the bottom conduction band to the top valence band⁹. For monolayer MBr₂ (M=Ru and Os), compressive strain can induce phase transitions in the materials from FVS to HVM to VQAH to HVM to FVS¹⁰. However, in these works, the intrinsic MAE as a function of strain has not been considered, and out-of-plane magnetic anisotropy is assumed to be fixed within considered strain range. Our recent works show that increasing strain can induce switched magnetic anisotropy from out-of-plane one to in-plane one⁷, and produce manifold electronic states. Thus, strain engineering may produce some complex phase transition of electronic states by tuning magnetic anisotropy.

In 2020, the septuple-atomic-layer 2D MoSi₂N₄ and WSi₂N₄ have been successfully synthesized by the chemical vapor deposition method¹¹. Subsequently, by intercalating a MoS₂-type monolayer MZ₂ into an InSe-type monolayer A₂Z₂, 2D MA₂Z₄ family with a septuple-atomic-layer structure has been constructed, with emerging topological, magnetic, valley and superconducting properties¹². Then, Janus 2D materials in the new 2D MA₂Z₄ family is proposed, such as MSiGeN₄ (M=Mo and W) and SrAlGaSe₄, and some novel properties can be achieved in these Janus materials, such as Rashba spin splitting and out-of-plane piezoelectric polarizations^{13,14}. Recently, Janus VSiGeN₄ monolayer is predicted to be a thermodynamically stable intrinsic 2D ferromagnet¹⁵.

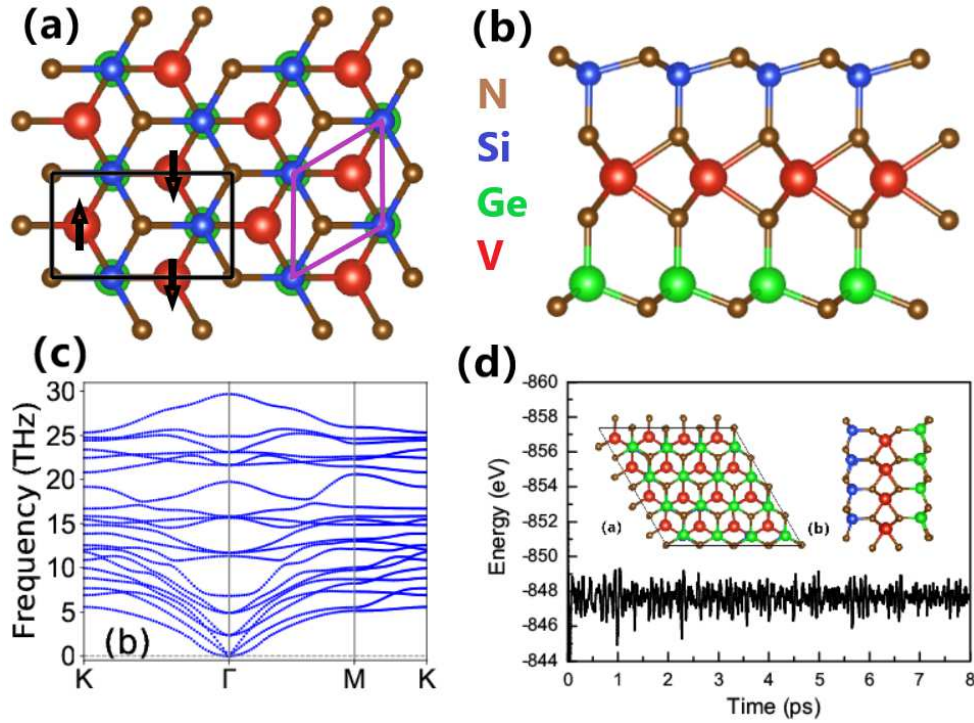


FIG. 1. (Color online) For VSiGeN₄ monolayer, (a): top view and (b): side view of crystal structure. The primitive (rectangle supercell) cell is shown by purple (black) lines, and the AFM configuration is marked with black arrows in (a). (c): the phonon dispersion curves. (d): the total energy fluctuations as a function of simulation time at 300 K, and insets show the final structures (top view (a) and side view (b)) of VSiGeN₄ after 8 ps at 300 K. .

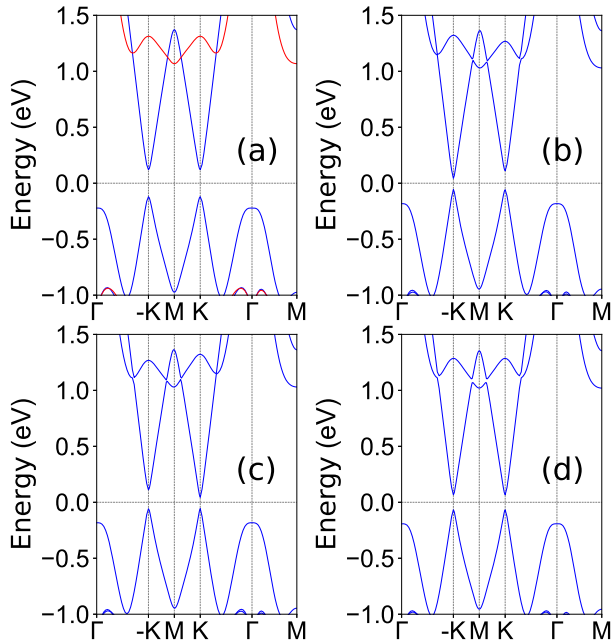


FIG. 2. (Color online) Energy band structures of VSiGeN₄ (a) without SOC; (b), (c) and (d) with SOC for magnetic moment of V along the positive z , negative z , and positive x direction, respectively. In (a), the blue (red) lines represent the band structure in the spin-up (spin-down) direction.

In this work, we investigate strain effects on magnetic anisotropy of Janus VSiGeN₄ monolayer, and reveal the importance of magnetic anisotropy in determining its magnetic, topological and valley properties. It is found that different strain strengths can drive the system into different novel electronic states (FVS, HVM and VQAHI) with fixed out-of-plane case, enabling a rich phase diagram. However, for in-plane case, only common FM states appear. With increasing a/a_0 , the magnetic anisotropy firstly switches from in-plane to out-of-plane. Further increasing a/a_0 will drive two additional transitions in the magnetic anisotropy from out-of-plane to in-plane to out-of-plane. The several transitions in the magnetic anisotropy are further identified by calculating MAE vs U . Our works highlight the role of magnetic anisotropy in V-based 2D MA₂Z₄ family materials, and deepens our understanding of strain along with magnetic anisotropy induced topological and valley states.

The rest of the paper is organized as follows. In the next section, we shall give our computational details and methods. In the next few sections, we shall present structure and stabilities, electronic states and strain effects on physical properties of VSiGeN₄ monolayer. Finally, we shall give our discussion and conclusion.

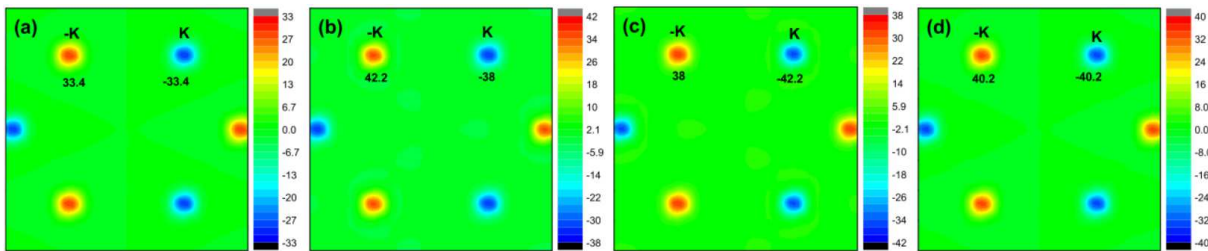


FIG. 3. (Color online) For VSiGeN₄ monolayer, the corresponding Berry curvature distribution of Figure 2 in 2D BZ.

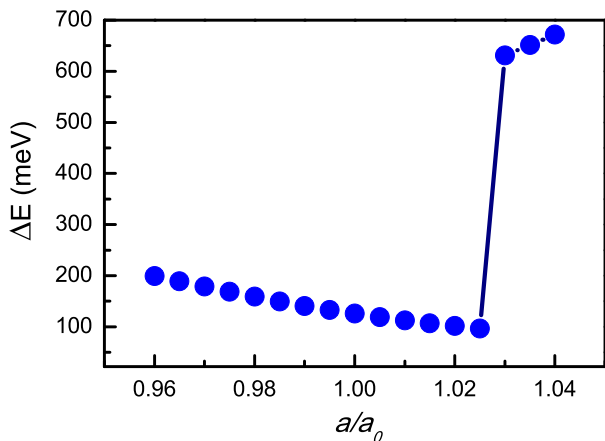


FIG. 4. (Color online) For VSiGeN₄ monolayer, the energy differences ΔE between AFM and FM ordering as a function of a/a_0 .

II. COMPUTATIONAL DETAIL

Within density-functional theory (DFT)¹⁶, we perform spin-polarized first-principles calculations by employing the projected augmented wave method, as implemented in VASP code^{17–19}. The generalized gradient approximation of Perdew-Burke-Ernzerhof (PBE-GGA)²⁰ is adopted as exchange-correlation functional. The energy cut-off of 500 eV, total energy convergence criterion of 10^{-8} eV and force convergence criteria of less than $0.0001 \text{ eV} \cdot \text{\AA}^{-1}$ on each atom are used to attain accurate results. A vacuum space of more than 30 Å is used to avoid the interactions between the neighboring slabs. The Γ -centered $16 \times 16 \times 1$ k-point meshes are sampled in the Brillouin zone (BZ) for structure optimization, electronic structures and elastic stiffness tensor, and $9 \times 16 \times 1$ Monkhorst-Pack k-point meshes for FM/antiferromagnetic (AFM) energy with rectangle supercell. The on-site Coulomb correlation of V atoms is considered by using GGA+ U method within the rotationally invariant approach proposed by Dudarev et al²¹, and the $U=3.2$ eV is used, which has been also used in ref.¹⁵. The spin-orbital coupling (SOC) effect is explicitly included to investigate MAE, electronic and topological properties of VSiGeN₄ monolayer.

The Curie temperature (T_C) of VSiGeN₄ is predicted

by Monte Carlo (MC) simulations with 40×40 supercell and 10^7 loops, as implemented in Mcsolver code²². The vibrational properties are investigated by the finite-displacement method with a $5 \times 5 \times 1$ supercell, as implemented in the Phonopy code²³. We use strain-stress relationship (SSR) to attain elastic stiffness tensor C_{ij} , and the 2D elastic coefficients C_{ij}^{2D} have been renormalized by $C_{ij}^{2D} = L_z C_{ij}^{3D}$, where the L_z is the cell height along z direction. The Berry curvatures are calculated directly from wave functions based on Fukui's method²⁴, as implemented in VASPBERRY code^{25,26}. The mostly localized Wannier functions including the d -orbitals of V atom and the p -orbitals of Si, Ge and N atoms are constructed on a k-mesh of $16 \times 16 \times 1$, and then are used to calculate edge states using Wannier90 and WannierTools packages^{27,28}.

III. STRUCTURE AND STABILITIES

As shown in Figure 1, this structure of VSiGeN₄ monolayer is stacked by seven atomic layers of N-Si-N-V-N-Ge-N. This can be regarded as a sandwich structure, and the middle VN₂ layer is sandwiched by SiN and GeN bilayers, which can be considered as a Janus structure. The VSiGeN₄ monolayer can be built by replacing the Si/Ge atoms of one of two SiN/GeN bilayers in VSi₂N₄/VGe₂N₄ monolayer with Ge/N atoms. The symmetry of VSiGeN₄ (No.156) is lower than that of VSi₂N₄/VGe₂N₄ (No.187) due to the lack of the reflection symmetry with respect to the middle VN₂ layer. The rhombus primitive cell and the rectangle supercell are plotted in Figure 1 (a) along with AFM configuration, and the first BZ with high-symmetry points is shown in FIG.1 of electronic supplementary information (ESI). The optimized lattice constants a of VSiGeN₄ monolayer is 2.959 Å with FM ordering, which agrees well with previous theoretical value (2.97Å)¹⁵.

Our calculations show that VSiGeN₄ stabilizes into a FM ground state, and the FM state is 125.7 meV lower in energy than its AFM state with rectangle supercell. The MAE of VSiGeN₄ is calculated from a energy difference between in-plane magnetization and out-of-plane magnetic anisotropy ($E_{MAE} = E_{(100)} - E_{(001)}$). The positive/negative MAE means that the easy magnetization axis is perpendicular/parallel to the plane of monolayer.

The calculated MAE of VSiGeN₄ is only $-3 \mu\text{eV}/\text{V}$ atom, indicating in-plane easy magnetization. The T_C is predicted within the Heisenberg model, which can be expressed as:

$$H = -J \sum_{i,j} S_i \cdot S_j - A \sum_i (S_i^z)^2 \quad (1)$$

where S_i (S_j)/ S_i^z is the spin vectors of each V atom/spin component parallel to the z direction, and J/A is the nearest neighbor exchange parameter/MAE. By comparing energies of AFM and FM ordering, the J with normalized spin vector ($|S|=1$) is 15.71 meV . The normalized magnetic moment and auto-correlation as a function of temperature are plotted in FIG.2 of ESI, and the predicted T_C is about 193 K . We find that the T_C of VSiGeN₄ is lower than that (338 K) by using the mean-field approximations¹⁵.

The dynamical stability of VSiGeN₄ is verified by its phonon band dispersion, which is presented in Figure 1 (c). Phonon branches show no any imaginary frequencies, indicating the dynamical stability of VSiGeN₄. Ab initio molecular dynamics (AIMD) simulations are further performed to examine the thermal stability of VSiGeN₄ on a $4 \times 4 \times 1$ supercell with a Nose thermostat of 300 K and a step time of 1 fs . As shown in Figure 1 (d), during the 8 ps simulation time, the energy are fluctuated around the equilibrium values without any sudden changes with small distortions in the final configurations, indicating its good thermal stability. The VSiGeN₄ has two independent elastic constants of C_{11} and C_{12} . If they satisfy Born criteria of $C_{11} > 0$ and $C_{11} - C_{12} > 0$ ²⁹, the VSiGeN₄ will be mechanically stable. The calculated two independent elastic constants of VSiGeN₄ are $C_{11}=434.15 \text{ Nm}^{-1}$ and $C_{12}=125.39 \text{ Nm}^{-1}$, which satisfy the Born criteria of mechanical stability, confirming its mechanical stability.

IV. ELECTRONIC STRUCTURES

The magnetic anisotropy has crucial effects on electronic states of some 2D materials⁴⁻⁷. It is well known that the magnetization is a pseudovector. And then, the out-of-plane FM breaks all possible vertical mirrors of the system, but preserves the horizontal mirror symmetry. The preserved horizontal mirror symmetry allows the spontaneous valley polarization and a nonvanishing Chern number of 2D system⁴. Although the magnetocrystalline direction of VSiGeN₄ monolayer is in-plane, this can be easily regulated into out-of-plane by external magnetic field due to very small MAE.

For VSiGeN₄ monolayer, the spin-polarized band structures by using both GGA and GGA+SOC are shown in Figure 2. Figure 2 (a) shows a distinct spin splitting due to the exchange interaction, and VSiGeN₄ is a direct band gap semiconductor with gap value of 0.242 eV . The valence band maximum (VBM) and conduction band bottom (CBM) are at K/-K point, which

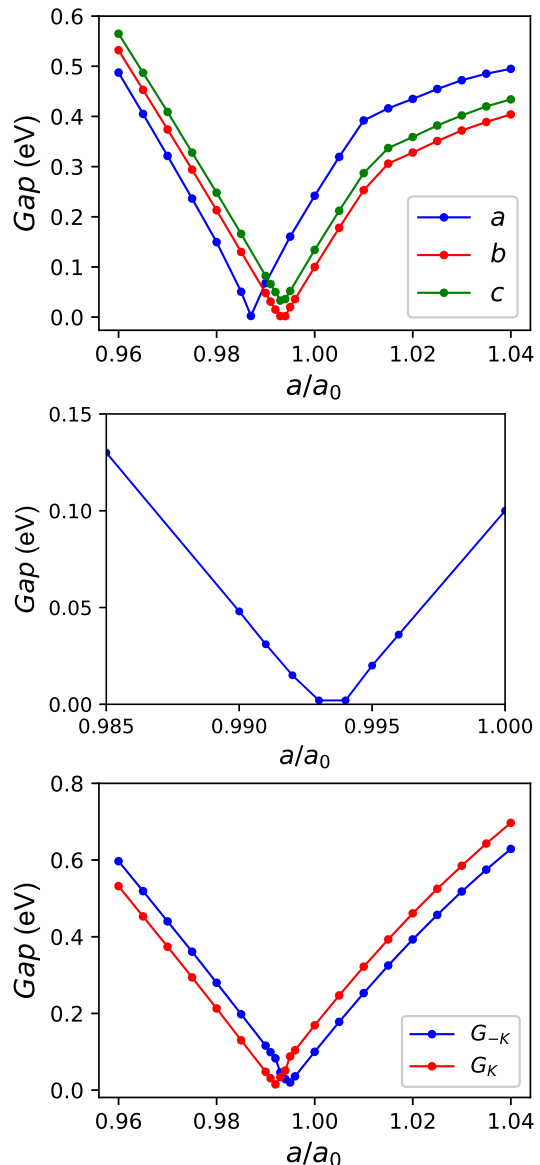


FIG. 5. (Color online) Top plane: the global energy band gap without SOC (a) and with SOC [out-of-plane magnetic anisotropy (b) and in-plane magnetic anisotropy (c)]; Middle plane: the enlarged view of global energy band gap with SOC [out-of-plane magnetic anisotropy] near $a/a_0=0.993$; Bottom plane: the energy band gaps for -K and K valleys as a function of a/a_0 with SOC [out-of-plane magnetic anisotropy].

are provided by the spin-up. The energies of -K and K valleys are degenerate for both conduction and valence bands. The V- d orbitals lie in a trigonal prismatic crystal field environment, and the d orbitals split into low-lying d_z^2 orbital, $d_{xy}+d_{x^2-y^2}$ and $d_{xz}+d_{yz}$ orbitals. According to projected band structure in FIG.3 of ESI, only top d_z^2 -dominated valence band in spin-up direction is occupied by one electron. This will lead to that the magnetic moment of each V atom is expected to be $1 \mu_B$, which conforms to calculated value $1.1 \mu_B$.

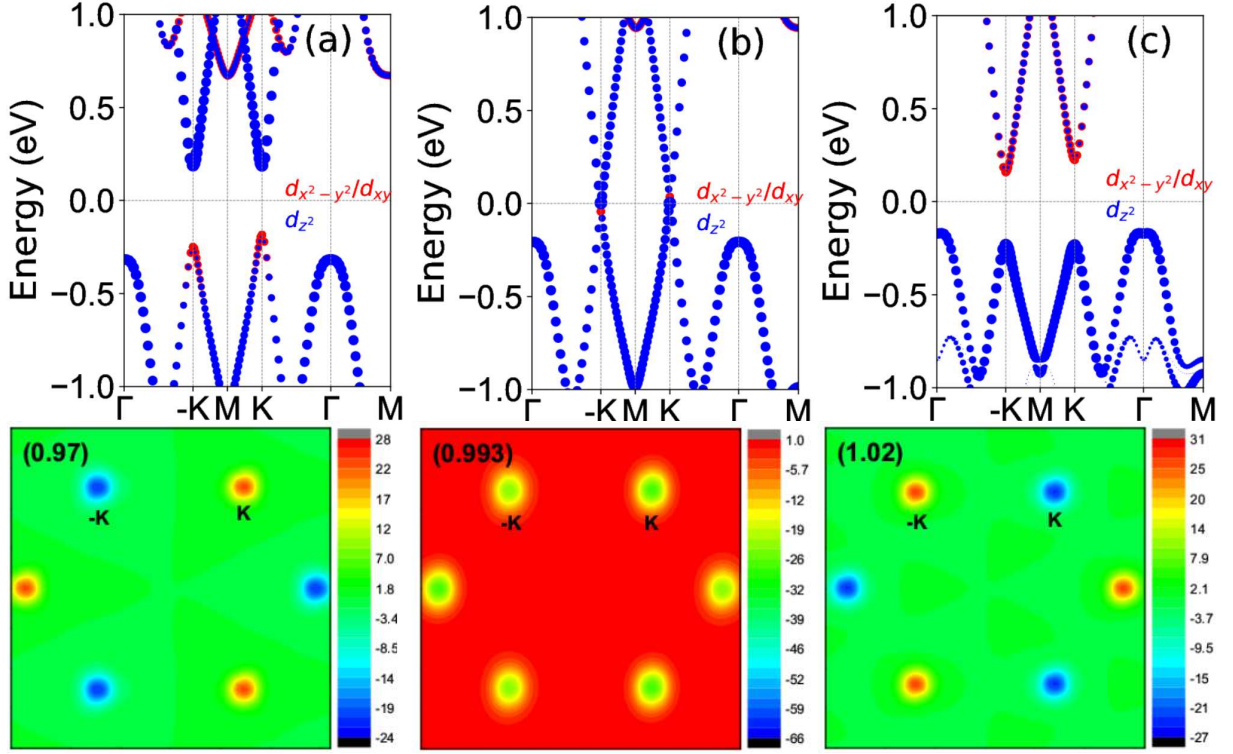


FIG. 6. (Color online) For VSiGeN₄ monolayer with out-of-plane magnetic anisotropy, the $V-d_{x^2-y^2}+d_{xy}$ and d_{z^2} -orbital characters energy band structures at representative $a/a_0=0.97$ (a), 0.993 (b) and 1.02 (c), along with the corresponding Berry curvature distribution in 2D BZ.

When including SOC, the valley polarization can be induced with out-of-plane magnetic anisotropy, as shown in Figure 2 (b). The valley splitting of bottom conduction band is 67 meV, while the valley splitting of top valence band is only 2 meV. For bottom conduction band, the energy of K valley is higher than one of -K valley. As plotted in Figure 2 (c), the valley polarization can be switched by reversing the magnetization direction (The energy of -K valley is higher than one of K valley.). Figure 2 (b) and (c) show that the gap value of VSiGeN₄ is about 0.10 eV. Based on Figure 2 (d), no valley polarization can be observed with in-plane magnetic anisotropy, and it is still a direct band gap semiconductor (0.134 eV).

FIG.3 of ESI show that $d_{x^2-y^2}+d_{xy}/d_z^2$ orbitals dominate -K and K valleys of bottom conduction band/top valence band, which determines strength of valley splitting. The intra-atomic interaction \hat{H}_{SOC}^0 from SOC mainly gives rise to valley polarization, which with out-of-plane magnetization can be expressed as³⁰⁻³² :

$$\hat{H}_{SOC}^0 = \alpha \hat{L}_z \quad (2)$$

where \hat{L}_z/α is the orbital angular momentum along z direction/coupling strength. The resulting energy of K or -K valley can be written as:

$$E^\tau = \langle \phi^\tau | \hat{H}_{SOC}^0 | \phi^\tau \rangle \quad (3)$$

where $|\phi^\tau\rangle$ (subscript $\tau = \pm 1$ as valley index) means the orbital basis for -K or K valley. If $d_{x^2-y^2}+d_{xy}$ orbitals

dominate -K and K valleys, the valley splitting $|\Delta E|$ can be written as:

$$|\Delta E| = E^K - E^{-K} = 4\alpha \quad (4)$$

If the -K and K valleys are mainly from d_{z^2} orbitals, the valley splitting $|\Delta E|$ is written as:

$$|\Delta E| = E^K - E^{-K} = 0 \quad (5)$$

According to FIG.3 of ESI, the valley splitting of bottom conduction band will be very large, and the valley splitting of top valence band will be very small, which agree well with calculated results. With general magnetization orientation, $\Delta E = 4\alpha \cos\theta$ ³² ($\theta=0/90^\circ$ means out-of-plane/in-plane direction.) for $d_{x^2-y^2}+d_{xy}$ -dominated -K/K valley. For in-plane one, the valley splitting of VSiGeN₄ will be zero.

When an in-plane longitudinal electric field E is applied, Bloch electrons can attain anomalous velocity v , which is associated with Berry curvature $\Omega(k):v \sim E \times \Omega(k)$ ³³. The calculated Berry curvature of VSiGeN₄ as a contour map in 2D BZ with and without SOC are plotted in Figure 3, and their hot spots are around -K and K valleys. The four situations all show that Berry curvatures have opposite signs around -K and K valleys with equal/unequal magnitudes for valley-nonpolarized/valley-polarized situation. When reversing the magnetization from z to $-z$ direction, the signs of

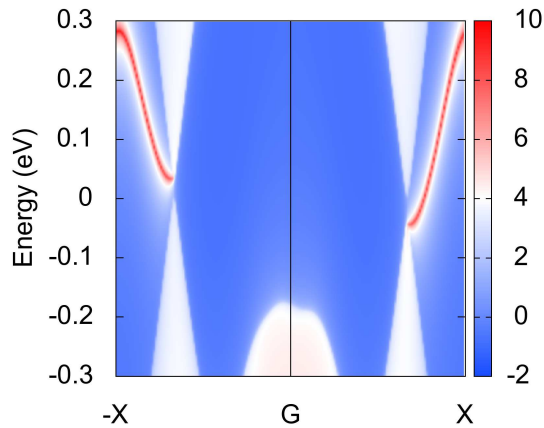


FIG. 7. (Color online) For VSiGeN₄ monolayer with out-of-plane magnetic anisotropy, the topological edge states at representative $a/a_0=0.993$.

Berry curvature at -K and K valleys remain unchanged, but their magnitudes exchange to each other. When the Fermi level falls between the -K and K valleys with appropriate electron doping, the Berry curvature forces the spin-up carriers of K valley to accumulate on one side of the sample by an applied in-plane electric field, giving rise to an anomalous valley Hall effect (AVHE). When the magnetization is reversed, the spin-down carriers of -K valley move to another side of the sample due to opposite Berry curvature compared with one of K valley.

V. STRAIN EFFECTS

Strain is a very effective method to tune electronic state of some 2D materials, and can produce novel electronic states, such as FV, QAH and HVM states^{7,9,10}. We use a/a_0 to simulate the biaxial strain, where a/a_0 are the strained/unstrained lattice constants. Here, both compressive ($a/a_0 < 1$) and tensile ($a/a_0 > 1$) strains are applied to achieve novel electronic states ($a/a_0: 0.96 \sim 1.04$). As shown in Figure 4, the total energy differences between AFM and FM ordering by using rectangle supercell indicate that the FM state is always the magnetic ground state of VSiGeN₄ in considered strain range. It is found that total energy differences between AFM and FM ordering at $a/a_0=1.03$ has a sudden jump. To explain this, the energies of AFM and FM ordering as a function of a/a_0 are plotted in FIG.4 of ESI. Calculated results show that the energy of AFM ordering suddenly increases at $a/a_0=1.03$. To further reveal the underlying causes, the magnetic moments of V atom for both AFM and FM ordering as a function of a/a_0 are plotted in FIG.5 of ESI. The energy difference jump is due to abrupt change of magnetic moment of V atom for AFM ordering, which reduces the magnetic interaction energy.

Next, the strain effects on electronic structures of VSiGeN₄ are investigated. Firstly, the total energy band

gaps as a function of a/a_0 without SOC are plotted in Figure 5, and energy band structures at some representative a/a_0 values are shown in FIG.6 of ESI. When the a/a_0 changes from 0.96 to 1.04, the gap firstly closes at about $a/a_0=0.987$, and then continues to increase. Before the energy gap closes, VSiGeN₄ is a direct gap semiconductor with VBM (CBM) at K/-K point. When $a/a_0 > 0.987$, VSiGeN₄ is still a direct gap semiconductor at small a/a_0 . When $a/a_0 > 1.01$, VSiGeN₄ is an indirect gap semiconductor. The CBM is at the K/-K point, whereas the VBM deviates slightly from Γ point. In considered strain range, the K and -K valleys are always provided by the spin-up.

When including SOC, the magnetic anisotropy has crucial effects on electronic structures of VSiGeN₄. Firstly, we consider that the magnetocrystalline direction of VSiGeN₄ is along out-of-plane. At some representative a/a_0 values, the energy band structures with GGA+SOC are plotted in FIG.7 of ESI, and the evolutions of total energy band gap along with those at -K/K point vs a/a_0 are shown in Figure 5. Calculated results show that there are two points around about $a/a_0=0.9925$ and 0.9945, where the total energy band gap is closed. At the two strain points, conduction electrons are intrinsically 100% valley polarized, and the HVM state can be realized³⁴. At about $a/a_0=0.9925$, the band gap of K valley gets closed, while a band gap at -K valley can be observed. At about $a/a_0=0.9945$, the band gap at -K valley is zero, while the band gap of K valley is kept. The considered strain (a/a_0) region can be divided into three parts by two HVM electronic states.

It is found that K and -K valleys of both valence and conduction bands are primarily contributed by $d_{x^2-y^2}+d_{xy}$ or d_{z^2} orbitals of V atoms, and the orbital characters energy band structures at representative $a/a_0=0.97, 0.993$ and 1.02 from three regions are plotted in Figure 6. For $0.96 < a/a_0 < 0.9925$, the $d_{x^2-y^2}+d_{xy}$ orbitals dominate K and -K valleys of valence bands, while the two valleys of conduction bands are mainly from d_{z^2} orbitals (For example $a/a_0=0.97$). When a/a_0 is between 0.9925 and 0.9945, the $d_{x^2-y^2}+d_{xy}/d_{z^2}$ orbitals dominate K valleys of conduction/valence bands, while orbital characters of -K valley remain unchanged (For example $a/a_0=0.993$). For $0.9945 < a/a_0 < 1.04$, the distributions of $d_{x^2-y^2}+d_{xy}$ and d_{z^2} orbitals are opposite to ones of $0.96 < a/a_0 < 0.9925$ (For example $a/a_0=1.02$). These mean that there are two-time band inversion between $d_{xy}+d_{x^2-y^2}$ and d_{z^2} orbitals with increasing a/a_0 . The first occurs at K valley, accompanied by the first HVM state. And, another is at -K valley, along with the second HVM state.

The two HVM states mean that the total gap of VSiGeN₄ closes and reopens two times, which suggests topological phase transition along with band inversion between $d_{xy}+d_{x^2-y^2}$ and d_{z^2} orbitals. The QAH state may appear, when a/a_0 is between 0.9925 and 0.9945. The edge states at representative $a/a_0=0.993$ are calculated to confirm QAH phase, which is plotted in Fig-

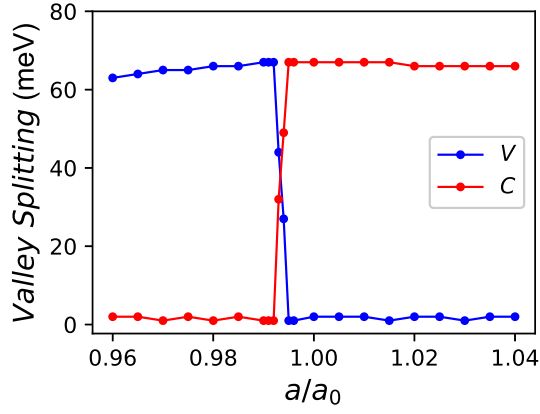


FIG. 8. (Color online) For VSiGeN₄ monolayer with out-of-plane magnetic anisotropy, the absolute value of valley splitting in both conduction (C) and valence (V) bands as a function of a/a_0 .

Figure 7. It is clearly seen that a nontrivial chiral edge state connects the conduction bands and valence bands, implying a QAH phase. The calculated Chern number $C=-1$, which is also obtained by integrating the Berry curvature (see Figure 6) within the first BZ. There are no nontrivial chiral edge states for the other two regions ($0.96 < a/a_0 < 0.9925$ and $0.9945 < a/a_0 < 1.04$). With increasing a/a_0 , two-time topological phase transitions can be observed in monolayer VSiGeN₄.

The transformations of Berry curvatures of K and -K valleys are related with these topological phase transitions, and the distributions of Berry curvature are plotted in Figure 6 at representative $a/a_0 = 0.97, 0.993$ and 1.02 . For $0.96 < a/a_0 < 0.9925$ and $0.9945 < a/a_0 < 1.04$, the Berry curvatures around -K and K valleys have the opposite signs and different magnitudes. However, for $0.9925 < a/a_0 < 0.9945$, the same signs and different magnitudes can be observed for Berry curvatures around -K and K valleys. When a/a_0 changes from 0.96 to 1.04, there are twice topological phase transitions, which are related the flipping of the sign of Berry curvature at -K or K valley. For the first topological phase transitions, the positive Berry curvature ($a/a_0=0.97$) changes into negative one ($a/a_0=0.993$) at K valley. The second topological phase transition is related with the sign flipping of Berry curvature of -K valley, and the negative Berry curvature ($a/a_0=0.993$) changes into positive one ($a/a_0=1.02$). These suggest that strain can induce sign-reversible Berry curvature at K or -K valley, and this is relevant to topological phase transition.

Calculated results show that VSiGeN₄ monolayer has spontaneous valley polarization, and the valley splitting for both valence and conduction bands is plotted in Figure 8. For $0.96 < a/a_0 < 0.9925$, the valley splitting of valence band is noteworthy, while the valley splitting of conduction band is very small. However, for $0.9945 < a/a_0 < 1.04$, the opposite situation can be observed for valley splitting, compared with the case

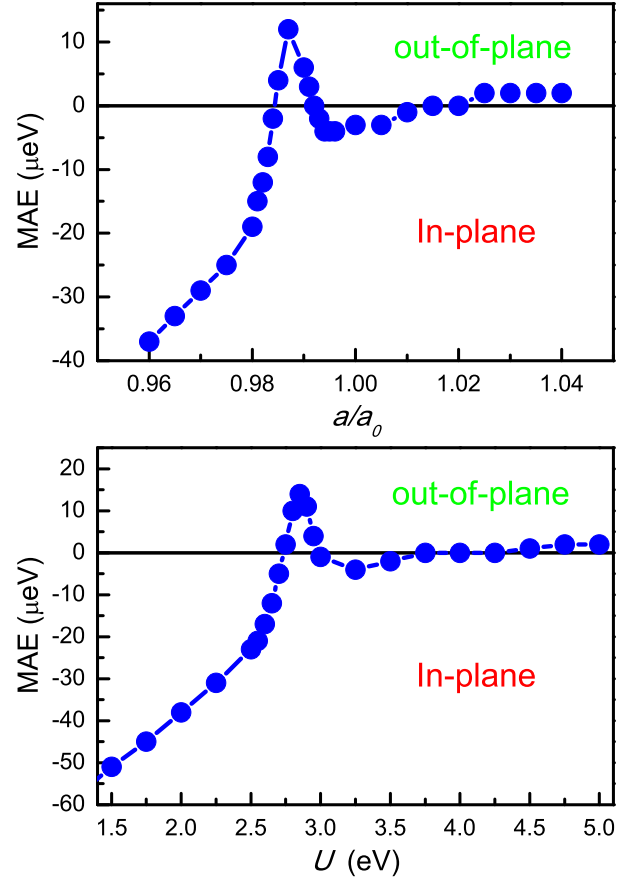


FIG. 9. (Color online) For VSiGeN₄ monolayer, the MAE as a function of a/a_0 (Top plane) and U (Bottom plane).

of $0.96 < a/a_0 < 0.9925$. These can be explained by the distributions of $d_{x^2-y^2} + d_{xy}$ and d_{z^2} orbitals (see Figure 6). If $d_{x^2-y^2} + d_{xy}/d_{z^2}$ orbitals dominate -K and K valleys, the valley splitting will be large/small. For $0.9925 < a/a_0 < 0.9945$, the valley splitting for both valence and conduction bands is observable. In this region, VSiGeN₄ is a VQAH with spontaneous valley splitting and chiral edge states. For VAQHI, the edge state has a special behavior of chiral-spin-valley locking. For example $a/a_0=0.993$, the edge state in Figure 7 is spin up with 100% spin polarization and 100% valley polarization, which is because the bands near the Fermi level are dominated by spin-up bands. The edge state only appears at the K valley due to the flipping of the sign of the Berry curvature or band inversion at K valley. When the magnetization is reversed, the edge state will move to the -K valley with an opposite spin direction and chiral.

In quick succession, we suppose the magnetocrystalline direction of VSiGeN₄ monolayer along in-plane one. The energy band gaps as a function of a/a_0 are plotted in Figure 5, and the representative energy band structures are shown in FIG.8 of ESI. When a/a_0 changes from 0.96 to 1.04, the gap firstly decreases, and then increases. The corresponding a/a_0 of gap close is about 0.993. It

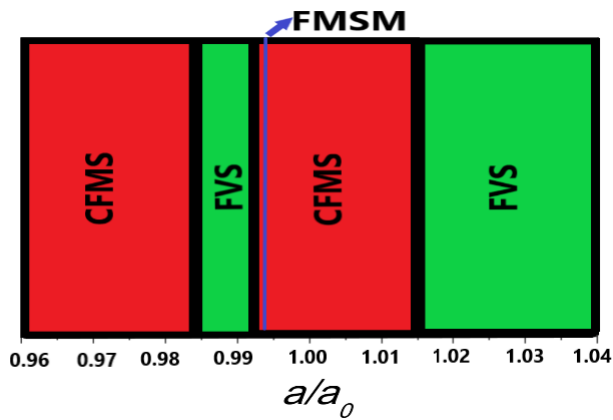


FIG. 10. (Color online) For VSiGeN₄ monolayer, the intrinsic phase diagram with different a/a_0 values, including common ferromagnetic semiconductor (CFMS), ferromagnetic semiconductor (FVS) and ferromagnetic semimetal (FMSM).

is found that no spontaneous valley polarization in both valence and conduction bands can be observed, and no QAH phase can be induced by strain. When a/a_0 is less than about 1.01 except 0.993 (semimetal), VSiGeN₄ is a direct gap semiconductor with VBM (CBM) at K/-K point. When $a/a_0 > 1.01$, VSiGeN₄ is an indirect gap semiconductor with CBM at the K/-K points, and the VBM deviates slightly from Γ point. In short, VSiGeN₄ monolayer is a common FM semiconductor or semimetal.

Finally, we plot the MAE as a function of a/a_0 in Figure 9 to determine intrinsic magnetic anisotropy of VSiGeN₄. Strain-driven complex magnetic anisotropy (multiple transitions in the magnetic anisotropy) can be observed. For $a/a_0 < 0.984$ and a/a_0 between 0.992 and 1.015, the VSiGeN₄ prefers an in-plane direction, whereas for a/a_0 between 0.984 and 0.992 and $a/a_0 > 1.015$, it favors an out-of-plane one. The intrinsic phase diagram of VSiGeN₄ monolayer is plotted in Figure 10. The electronic state includes common ferromagnetic semiconductor (CFMS), FVS and ferromagnetic semimetal (FMSM), and no QAH phase exists. However, the QAH phases can be easily achieved by external magnetic field due to small MAE for a/a_0 between 0.9925 and 0.9945.

VI. DISCUSSION AND CONCLUSION

Monolayer RuBr₂ shows the same electronic states induced by strain with VSiGeN₄ for both out-of-plane and in-plane cases⁷. However, the MAE of RuBr₂ varies monotonously with increasing a/a_0 . The strain can suppress/enhance the kinetic energy of electron, and then effectively enhances/suppresses the correlation effect⁵. This means that electronic correlation can induce the similar change of electronic states and MAE with strain, which has been confirmed for RuBr₂⁷. To further confirm complex strain dependence of MAE, we calculate the MAE as a function of correlation strength U , which is also plotted in Figure 9. It is clearly seen that the MAE vs between a/a_0 and U show very similar outline, as is expected. The complex strain dependence of MAE can be readily extended to VSi₂P₄, VSi₂N₄, VSiSnN₄ and so on, because they share the same crystal structure with VSiGeN₄. In fact, for VSi₂P₄, one can observe similar transitions in the MAE as a function of U ⁵.

In summary, we have demonstrated that strain can result in a different phase diagram for different magnetic anisotropy (out-of-plane and in-plane cases). For out-of-plane situation, the strain can induce novel VQAH with exotic chiral-spin-valley locking edge states between two HVM states, and these are related with sign-reversible Berry curvature and band inversions of $d_{xy} + d_{x^2-y^2}$ and d_{z^2} orbitals at -K and K valleys. For in-plane situation, VSiGeN₄ is a CFMS without spontaneous valley polarization. Particularly, the calculated intrinsic MAE shows that multiple transitions in the magnetic anisotropy can be induced by strain, which is further confirmed by calculating MAE vs U . Intrinsically, there is not a VQAH, which can be realized by external magnetic field. Our works deepen our understanding of strain effects in the V-based 2D MA₂Z₄ family materials, and it will open new perspectives for multifunctional electronic device applications based on these materials.

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